CHAPTER - I

- 1.1 Introduction.
- 1.2.1 Concept of humidity.
- 1.2.2 Porosity / Pore size.
 - 1.3 Moisture sensing devices.
- 1.3.1 Electrical hygrometer.
- 1.3.2 Spectroscopic hygrometer.
- 1.3.3 Hair hygrometer.
 - 1.4 Work done on porous Al_2O_3 .
 - 1.5 Vacuum technique for thin film deposition.
- 1.5.1 Physical methods.
- 1.5.1.1 Vacuum evaporation.
- 1.5.1.1.1 Resistive heating.
- 1.5.1.1.2 Flash evaporation.
- 1.5.1.1.3 Electron beam bombardment.
- 1.5.1.1.4 Laser evaporation.
 - 1.5.1.2 Sputtering.
 - 1.5.2 Chemical methods.
 - 1.6 Refractive index.
 - 1.7 Adhesion.
 - 1.7.1 Scotch tape method.
 - 1.7.2 Abresion method.
 - 1.7.3 Direct pull method.
 - 1.7.4 Moment or Topple method.

- 1.7.5 Ultracentrifugal method.
 - 1.8 Electrical Resistance.
 - 1.9 IR and XRD Spectroscopy.
 - 1.10 Aim and Scope of present work.

CHAPTER - II

Experimental methods for formation of Al_2O_3 and study of properties.

- 2.1 Deposition system.
- 2.2 Substrate cleaning.
- 2.3 Aluminium film deposition.
- 2.4 Al₂O₃ film preparation.
- 2.4.1 Hot water oxidation.
- 2.4.2 Steam oxidation.
 - 2.5 Thickness measurements.
 - 2.6 Abele's method for finding refractive index.
 - 2.7 Adhesion measurement.
 - 2.8 System for D.C. resistance meaurement.
 - 2.9 System for aging studies.
- 2.9.1 System for exposing to humidity.
- 2.9.2 System for exposing to heat.
- 2.9.3 Sequencial effect studies.
- 2.10 IR and XRD studies.
- CHAPTER III

RESULTS

- 3.1 Introduction.
- 3.2 General plan in the present work.

3.3 Data of refractive index.

- 3.3.1 Fresh film.
- 3.3.2 Porosity data.
- 3.3.3 Study of ambient effects on porous Al_2O_3 films.
- 3.3.3.1 Effect of saturated moisture.
- 3.3.3.2 Effect of repeated sequencial exposure.
- 3.3.3.3 Effect of heat.
 - 3.4 Adhesion.
 - 3.4.1 Fresh films.
 - 3.4.2 Ambient effect on adhesion.
- 3.4.2.1 Effect of saturated moisture.
- 3.4.2.2 Effect of heat.
 - 3.5 D.C. Resistance.
 - 3.5.1 I-V Characteristics.
 - 3.5.2 Ambient effect on D.C. Resistance.
- 3.5.2.1 Effect of saturated moisture.
- 3.5.2.2 Variation with relative humidity.
- 3.5.2.3 Moisture-heat-air cycle.
- 3.5.2.4 Effect to 98% moisture-air cycling.
 - 3.6 IR and XRD studies
 - 3.6.1 IR studies.
 - 3.6.2 XRD studies.
 - 3.7 Summary of some important results.

CHAPTER - IV

DISCUSSION

- 4.1 Indroduction.
- 4.2 Formation of porous Al₂O₃.
- 4.3 Steam oxidised and hot water oxidised ${\rm Al}_2{\rm O}_3$ thin films
- 4.4 Refractive index of steam oxidised Al_2O_3 thin films.
- 4.5 Adhesion.
- 4.6 D.C. Resistance.
- 4.7 Conclusion.
- 4.8 Scope for further work.